

PMT orders maskless lithography system from EV Group for advanced memory wafer probe card manufacturing - January 24, 2024

PMT has ordered a LITHOSCALE® maskless exposure system from EVG. "Fine-pitch probe card manufacturing involves many lithographic patterning steps, which can significantly drive up cost of ownership." stated Dr. Yong-Ho Cho, CEO of PMT. Incorporating EVG's MLE™ (maskless exposure) technology, LITHOSCALE addresses lithography needs for markets and applications that require a high degree of flexibility or product variation. LITHOSCALE tackles legacy bottlenecks by combining powerful digital processing that enables real-time data transfer and immediate exposure, high structuring resolution and throughput scalability.



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